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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/687,158	10/16/2003	Hryhory T. Koba	17310-281350	6636	
25764	7590 11/20/2006		EXAMINER		
FAEGRE & BENSON LLP			CHAUDHRY, SAEED T		
PATENT DOCKETING 2200 WELLS FARGO CENTER		ART UNIT	PAPER NUMBER		
90 SOUTH SEVENTH STREET			1746		
MINNEAPO	LIS, MN 55402-3901		DATE MAILED: 11/20/2006	DATE MAILED: 11/20/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Ta Caralla					
		Application No.	Applicant(s)				
		10/687,158	KOBA ET AL.				
	Office Action Summary	Examiner	Art Unit				
	<u> </u>	Saeed T. Chaudhry	1746				
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHOWHIC - Externafter - If NO - Failur Any r	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DAINS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Openiod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be timwill apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONED	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status							
2a)⊠	Responsive to communication(s) filed on This action is FINAL . 2b) This Since this application is in condition for allowan closed in accordance with the practice under E	e action is non-final. nce except for formal matters, pro					
Dispositi	ion of Claims						
5)□ 6)⊠ 7)□ 8)□	Claim(s) 1-18 is/are pending in the application. 4a) Of the above claim(s) 15-18 is/are withdraw Claim(s) is/are allowed. Claim(s) 1-14 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or	vn from consideration.					
	on Papers						
10)	The specification is objected to by the Examiner The drawing(s) filed on is/are: a) access applicant may not request that any objection to the construction and the correction of the correction of the construction of the correction of the construction of the correction of the correction of the construction of the correction of the construction of the correction of the construction of the constructi	epted or b) objected to by the Edrawing(s) be held in abeyance. See ion is required if the drawing(s) is obje	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).				
Priority u	ınder 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
Attachment	u(s)						
I) Notice 2) Notice 3) Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	4) Interview Summary (Paper No(s)/Mail Dat 5) Notice of Informal Pa 6) Other:	te				

DETAILED ACTION

Applicant's amendments and remarks filed September 12, 2006 have been acknowledged by the examiner and entered. Claims 1-18 are pending in this application. Of the above 15-18 are withdrawn from consideration.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made

The factual inquiries set forth in Graham v. John Deere Co., 148 USPQ 459, that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

- 1. Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or unobviousness.

Claims 1-4 and 9-10 are rejected under 35 U.S.C. § 103(a) as being unpatentable over Albrecht et al in view of Boquillon et al or Yeung et al.

Albrecht et al (6,288,876) discloses a head suspension for a rigid disk drive, which include all the components as claimed herein. The reference discloses a lift tab for a load/unload type of data storage hard drive and a method of smoothing the lift tab. The method includes the step of striking the lift tab with short duration (e.g. 10-500 nanosecond) energy pulses to melt a thin surface layer of the lift tab. The melted layer flows under surface tension forces, smoothing out bumps and scratches. The melted layer quickly refreezes, forming an exceptionally smooth melted and refrozen spot. Preferably, the melted and refrozen spot is 0.2-10 microns deep. More preferably, the melted and refrozen spot is in the range of 1.0 to 3.0 microns thick. The size of the melted and refrozen spots is practically limited by power

available from energy sources such as lasers. Preferably, the melted and refrozen spots are at least several tens of microns in diameter. Also, the present invention includes head gimbal assemblies and hard drives having lift tabs with melted and refrozen spots (see abstract).

FIG. 8 shows a head gimbal assembly 54 having the lift tab 20 smoothed according to the method of the present invention. The head gimbal assembly includes a mounting portion 56 for attachment to a rotary actuator (not shown) inside a data storage hard drive. A rigid arm 58 and flexible suspension 60 are attached to the mounting portion 56. The flexible suspension 60 supports a slider 62 which comprises a magnetic read/write head (not shown). The lift tab 20 is attached to the flexible suspension such that the lift tab can cause the flexible suspension to bend slightly when subject to a force (see col. 8, lines 1-11).

In a specific implementation of the present method, a multimode frequency doubled Nd:YLF (527 nm) laser is used. The pulse duration is 200 ns at a repetition rate of 100 Hz. The laser pulses are focused to a spot size of about 300 microns by 70 microns. The pulse energy incident on the lift tab is 2.8 millipules per pulse (see col. 7, lines 58-62).

When the energy pulse strikes the lift tab surface, melted material flows away from the melted spot due to thermal expansion. The melted material then refreezes rapidly due to fast heat diffusion. This creates roughness with a length scale comparable to the spot size (and ripples 36 shown in FIG. 4). Therefore, it is desirable in the present method for each melted spot 28 to be as large as practically possible (see col. 7, lines 18-30).

As a specific example on stainless steel using 527 nm laser light, a 10 nanosecond energy pulse duration at about 130 Mw/cm.sup.2 produces melted spots having melted depth of about

0.7 micron. A 200 nanosecond pulse duration at about 70 Mw/cm.sup.2 produces melted spots having melted spot depth of about 2-3 microns (see col. 5, lines 59-64).

Albrecht et al reference specifically did not disclose to clean the contaminated surface of the head suspension but since the reference discloses to irradiating pulses of a laser beam on the lift tab, which inherently clean the contaminated surface. The reference discloses that it is desirable for each melted spot to be as large as practically possible. Therefore, single pulse extend across the entire contaminated surface. The reference fails to disclose that the laser energy is insufficient to melt the surface itself or without melting the surface itself.

Boquillon et al (5,151,134) disclose a method for cleaning surface by applying laser pulses to the surface in the absence of an observable thermal effect to the object (see claims).

Yeung et al (5,482,561) disclose a method of removing contaminants from the surface of sand particles by applying laser without significant heating of the underlying sand particles (see abstract and claims).

It is well known in the art to heat the contaminants with the laser beam without heating the underlying surface and vaporizing contaminants as disclosed by Boquillon et al and Yeung et al. Therefore, it would have been obvious at the time applicant invented the claimed process to incorporate the teachings of Boquillon et al or Yeung et al into the process of Albrecht et al process to remove contaminants from the surface without melting the surface and vaporizing the contaminants to avoid changing the surface physical characteristics.

Claims 5-8 and 11-14 are rejected under 35 U.S.C. § 103(a) as being unpatentable over Albrecht et al in view of Boquillon et al or Yeung et al as applied to claims 1-4 and 9-10 above, and further in view of Hosoya et al.

Albrecht et al were discussed <u>supra</u>. However, the reference fails to disclose a step of interposing a mask between a source of laser beam and the surface to be cleaned.

Hosoya et al (5,319,183) disclose a method for cleaning a printed wiring board, wherein a pulsed laser beam is irradiated onto a printing wiring board to evaporate the irradiated portion. A laser beam irradiating apparatus 2 emits a laser beam to a pattern spot on the wiring board placed on the XY stage 1. The laser beam apparatus comprising a laser oscillator 21 and a laser beam masking apparatus 22, and is connected to a laser controller 23 and mask size controller 24. The laser controller 23 controls the number of oscillations and the output of the laser oscillator 21. The mask size controller 24 controls the opening length L and width W of the laser beam masking apparatus 22. The controller 24 controls the laser beam masking apparatus 22 in a such as way that during a removal of molten substances, the irradiation area is enlarged (see col. 6, lines 35-44 and Fig. 4).

It would have been obvious at the time applicant invented the claimed process to incorporate a mask between the source of laser beam and the surface or between the lens and the surface as disclosed by Hosoya et al into the process of Albrecht et al to control the size of the laser beam for the contaminated surface such that the only contaminants are irradiate by the laser beam, which would protect the other area from damage.

Response to Applicant's Arguments

Applicant argued that the Albrecht patent is directed to a method of smoothing lift tab surfaces by rapidly melting the surface of the lift tab with pulsed laser beam. The melting and refreezing process fills surface microcracks so that the melted surface refreezes with a smooth surface finish. The melted spot of the lift tab surface has different physical characteristics than

the bulk of the lift tab due to the melting and refreezing process. The Albrecht patent fails to teach or suggest a method of cleaning a contaminated surface as recited in claim 1.

This argument is not persuasive because Albrecht is cited to show that it is known in the art to clean the contaminated surface on a head suspension for a rigid disk drive.

Applicant argued that there is no motivation to combine the Albrecht patent with either of the Yeung or Boquillon patents because doing so would render the method of the Albrecht patent operable.

This argument is not persuasive because it is known in the art to vaporize the contamination from the surface as disclosed by Yeung or Boquillon and Albrecht discloses that it is known in the art to clean contaminated surface on a head suspension for a rigid disk drive. Therefore, one of ordinary skill in the art would expect that using laser energy for vaporizing the contamination from a surface as disclosed by Yeung or Boquillon would vaporize the contaminants from the surface of the contaminated head. Further, For a finding of obviousness within the meaning of 103, the references themselves need not explicitly suggest the combination of their features where all the references pertain to the same field of endeavor such as laser cleaning. The test is what the combined teachings of the references, taken collectively would have suggested to one of ordinary skill in the art (see Cable elec. Prods., Inc. V. Genmark, Inc., 770 F.2d 1015, 1025, 226 USPQ 881, 886-87 (Fed. Cir. 1985 and In re Keller, 642 F.2d 413, 425, 208 USPQ 871, 881 (CCPA 1981)).

Applicant's arguments filed September 12, 2006 have been fully considered but they are not persuasive.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Saeed T. Chaudhry whose telephone number is (571) 272-1298. The examiner can normally be reached on Monday-Friday from 9:30 A.M. to 4:00 P.M.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mr. Michael Barr, can be reached on (571)-272-1414. The fax phone number for non-final is (703)-872-9306.

When filing a FAX in Gp 1700, please indicate in the Header (upper right) "Official" for papers that are to be entered into the file, and "Unofficial" for draft documents and other communication with the PTO that are for entry into the file of the application. This will expedite processing of your papers.

Any inquiry of a general nature or relating to the status of this application should be directed to the Group receptionist whose telephone number is (571) 272-1700.

Saeed T. Chaudhry

Patent Examiner

MICHAEL BARR SUPERVISORY PATENT EXAMINER